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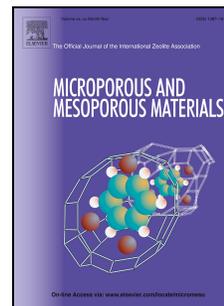
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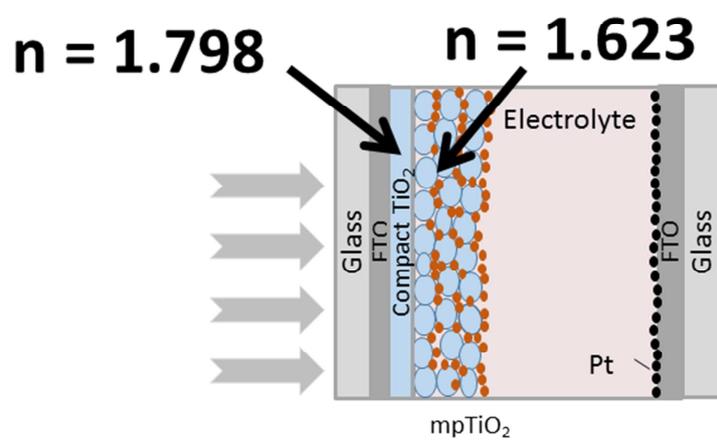
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ACCEPTED MANUSCRIPT

## Refractive Index and Scattering of Porous TiO<sub>2</sub> Films

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### Abstract

Porous titanium dioxide (TiO<sub>2</sub>) films are essential components of dye sensitized solar cells (DSSCs) as well as perovskite solar cells (PSCs). Unfortunately, porosity, refractive index, and scattering properties of these films are only roughly known. This induces uncertainties in modelling and understanding of these solar cells. Since the literature provides only descriptions of the optical properties of the porous TiO<sub>2</sub> layers with unclear relevance to these solar cells, we investigate porous TiO<sub>2</sub> films really used in DSSCs and potentially usable in PSCs. The effective refractive index and the film porosity for different nanostructures that were fabricated from solution-based techniques were determined. The found values are  $1.7982 \pm 0.005$  for the effective refractive index of one kind of TiO<sub>2</sub> films and  $1.62 \pm 0.002$  for another one. These values lead to porosities of 53.5% and 65%, respectively. The scattering of the films can be described by a wavelength-independent effective scattering parameter for one film type and by effective scattering particles with a diameter of 46.5 nm for the other film type. The determined porosities are also of relevance for the ionic transport which is functionally crucial in DSSCs and a disturbance in PSCs.

### Keywords:

Porous titanium dioxide, Dye sensitized solar cells, Refractive index calculation, Scattering, Optical characterization, FDTD simulation.

## 1. Introduction

Titanium dioxide is an n-type indirect band gap semiconductor. It has a wide range of applications due to its various optical, electrical and chemical characteristics [1-8]. Among the many  $\text{TiO}_2$  modifications, the mesoporous structure is crucial in dye-sensitized solar cells (DSSCs) [9, 10] as well as perovskite solar cells (PSCs) [11, 12]. DSSCs contain two different semiconductor layers, the so-called mesoporous layer and the so-called blocking layer, as shown in Figure 1. While the first is essential for the charge separation, electron collection and ion conduction, the second is intended for suppressing the loss of generated electrons to the electrolyte. Both layers consist of the same chemical compound,  $\text{TiO}_2$ , but they have different mesostructures. For PSCs, the perovskite is deposited on a mesoporous particle  $\text{TiO}_2$  structure for a better  $I$ - $V$  characteristics [13].

The mesoporous particle  $\text{TiO}_2$  films (mpp- $\text{TiO}_2$ ) of DSSCs are composed of nanoparticles in the range from 10 to 30 nm leading to a very large internal surface. Therefore, the amount of dye adsorbed in a DSSC is very high and an absorption capability of the dye to near 100% over a wide range of the visible spectral region is achieved. By virtue of comparison, the amount of adsorbed dyes on the surface of single crystals and poly-crystal materials is quite small, causing only about 1% absorption even at the peak wavelength [9]. On the other hand, the  $\text{TiO}_2$  blocking layer of DSSCs, which we henceforth call the “compact layer” (comp $\text{TiO}_2$ ), has only very small pores since it should block ion transport.

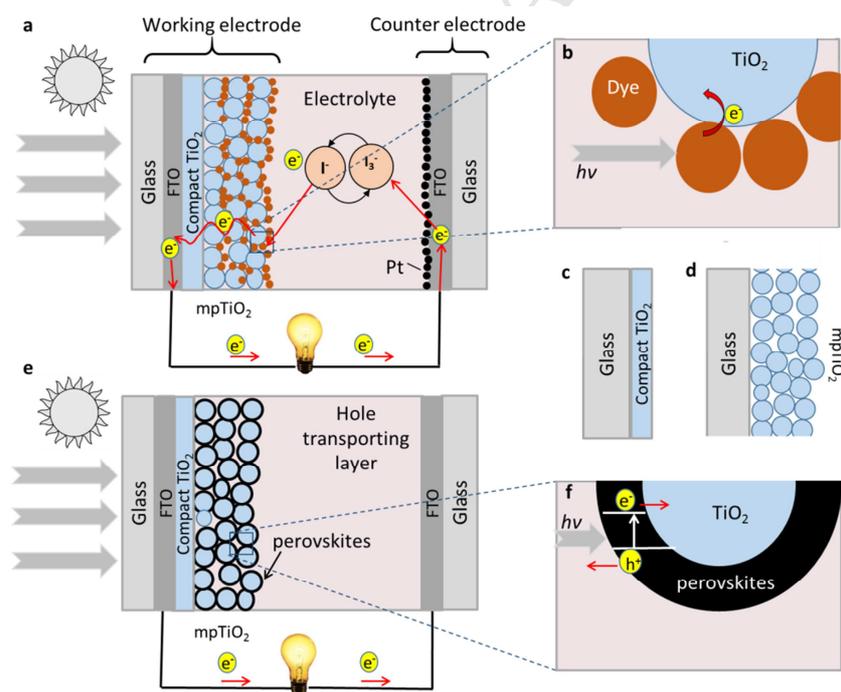


Figure 1: (a) Schematic of a DSSC with the operation principle and all optically relevant layers. (b) Photo-induced electron transfer in DSSC, (c) compact and (d) mesoporous particle  $\text{TiO}_2$  layers on glass, investigated in this work. (e) Schematic of one kind of PSC with the operation principle and all optically relevant layers. (f) Photo-induced processes in this kind of PSC.

For PSCs, the use of a mesoporous particle  $\text{TiO}_2$  layer was reported to improve the electron extraction, and promote the formation of a compact perovskite layer with large grains. Therefore, the performance of the PSCs is significantly improved [14]. Furthermore, the  $\text{TiO}_2$ -embedded perovskite films exhibit an improved long-term stability than the pristine perovskite films [14].

A crucial step in the numerical analysis of solar cells especially of DSSCs for optimization purposes is the use of appropriate optical models and material constants. Different deposition techniques and even various conditions for the same technique yield different microstructures and therefore different pore densities [15]. Since the refractive index of  $\text{TiO}_2$  films is dependent on its density [16], several techniques were exploited to characterize  $\text{TiO}_2$  layers [17-20]. Using capacitance-voltage measurements, the refractive permittivity of nanocrystalline  $\text{TiO}_2$  thin films deposited on silicon using sol-gel spin coating was found to have a value of 25 [17]. Optical waveguide spectroscopy was used in [18] to follow the real-time diffusion of the dye N-719 dye into the mesoporous nanocrystalline  $\text{TiO}_2$  films similar to those used in DSSCs. The experimental data were fitted to a value of 1.7942 for the refractive index of the porous  $\text{TiO}_2$  before dye attachment. The inclusion of organic compounds in the fabrication process of  $\text{TiO}_2$  films yielded an organic- $\text{TiO}_2$  nanocomposite that has a tunable refractive index between 1.76 and 2.05 at a wavelength of 589 nm [19]. All these works on  $\text{TiO}_2$  films make clear that the determination of relevant optical parameters for solar cells (DSSCs and PCSs) has to be done exactly on these  $\text{TiO}_2$  films fabricated with the solar cells-specific methods leading to specific porosities.

In this work, we introduce a detailed optical investigation for both the comp $\text{TiO}_2$  and the mpp- $\text{TiO}_2$  films acting as blocking and active layers in DSSCs. Having accurate values for the porosity, the refractive index, the scattering and the thickness of the different  $\text{TiO}_2$  layers is crucial for developing trustworthy simulation tools for DSSCs. Usually, estimated values of these parameters are used. Herein, efficient techniques are introduced to obtain the values of these parameters. In addition, the description of the optical scattering phenomena in these functionally important layers is improved.

## 2. Experimental details

In DSSCs, the thickness of the comp $\text{TiO}_2$  layer is usually below 200 nm whereas that of the mpp- $\text{TiO}_2$  is in the range from 5 to 15  $\mu\text{m}$ . Different fabrication techniques are used for each layer. The thin comp $\text{TiO}_2$  samples used in this work were prepared with a sol-gel method via the spin-coating technique. This process is known to yield thin, homogeneous layers of controllable film morphology on numerous substrates [21]. It is widely used for DSSCs [22] as one possibility; alternatives are dip-coating (e.g. in [23]) or spray pyrolysis [24]. The thicker mpp- $\text{TiO}_2$  layers were fabricated using screen printing as in [25]. The alternative method of doctor blading (without a screen but with appropriate spacers) is expected to result in very similar films (e.g. in ref. [23]). A *JV* characteristics of a DSSC fabricated with the procedures below is given in the Supplementary Data section.

## 2.1 Fabrication of compact TiO<sub>2</sub> samples

In order to prepare a compTiO<sub>2</sub> film on a BK7 glass substrate [26], volumes of 250  $\mu\text{L}$  of a precursor solution were dropped onto  $2.5 \times 2.5 \text{ cm}^2$  substrates placed in a spin coater (Spin150, SPS-Europe). The precursor solution was prepared at room temperature by mixing the titanium isopropoxide with ethanol and acetic acid as in [17]. A low spin-coating speed of 500 rpm at the beginning for 10 s enabled a uniform distribution of the solution across the sample, followed by a 3000 rpm step for 60 s with constant acceleration of 1000 rpm/s. Finally, the samples were heated in an oven within 60 min to 120 °C and remained for another 60 min at this temperature. Samples prepared as such have shown acceptable homogeneity in its interference color and the visually the same interference color when comparing different samples. The first sample (010-01) of the series (random selection) was taken for the further analysis. Sometimes, the influence of support surface roughness on the film properties is discussed. We have no indication for such an influence for our special deposition method. Therefore, we consider the properties of comp-TiO<sub>2</sub> on BK7 (as representative for many supports. BK7 has a roughness in the atomic range [26]) excluding any scattering effects from the BK7 surface.

To tune the thickness of the films, the deposition conditions were changed slightly, seeking for thicker layers leading to more pronounced Fabry-Perot oscillations. As examples three different samples were fabricated with lower rotation speed. The first sample (012-01) was coated for 6 s under a speed of 500 rpm and acceleration of 2000 rpm/s followed by 10 s under the speed of 2000 rpm with the same acceleration. The second sample (013-01) was coated for 6 seconds under a speed of 500 rpm and acceleration of 2000 rpm/s followed by 10 s under speed of 1000 rpm with 500 rpm/s acceleration. Finally, the third sample (014-01) was coated in the same way as the second one, but with a circular sample holder instead of the rectangular one used for the first two samples. In addition, multilayer deposition was used for sample 011-03 where 5 layers were deposited using the same procedure as for sample 014-01.

## 2.2 Fabrication of mpp-TiO<sub>2</sub> samples

In order to deposit mpp-TiO<sub>2</sub> films with a thickness between 5 to 15  $\mu\text{m}$  the manual screen-printing method was used. The paste was the same as in ref. [23] and consisted of titania nanopowder, terpineol, ethyl cellulose, acetic acid, and isopropanol, mixed with the same procedure as in ref. [23] Here, five mpp-TiO<sub>2</sub> samples were prepared on glass substrates (BK7) and on quartz glass under the same conditions. The complex composition of the paste results from an optimizing process for the adjustment of titania surface termination, solid content, viscosity, and drying behavior.

## 2.3 Characterization

The optical characterization of the fabricated samples was done using a Cary 5G UV-Vis-NIR spectrometer against air as reference. The spectrometer was supplemented by a rotating stage as described in [27].

### 3. Results and discussion

#### 3.1 Spectroscopic results for the different TiO<sub>2</sub> films

For the compact TiO<sub>2</sub> films, it can be observed (Figure 2a) that Fabry-Perot oscillations start to appear for the thickest samples making it possible to estimate the film thicknesses. An accurate determination of the film thickness must, however, be connected with a simultaneous determination of the refractive index. This will be calculated in the next section.

Regarding the mpp-TiO<sub>2</sub>, the five samples were characterized using the UV-Vis-NIR spectrometer. Although the samples were fabricated according to the same procedure, significant fluctuations in their spectra can be observed in Figure 2b. We attribute these differences to thickness variations, as the manual screen printing method typically yields a layer thickness in a larger range [28].

The extinction spectrum ( $E = -\log_{10} T$  with  $T$  for the transmission) of one of these samples is shown in Figure 3. The starting wavelength is chosen to be 400 nm, so that the extinction curve reflects mainly the scattering due to this type of mesoporous layer with no absorption effects [29]. It's worth noting that the extinction that is directly determined from transmission data generally results from a superposition of absorption, reflection, and scattering effects.

#### 3.2 The effective refractive index of the compact TiO<sub>2</sub> layer

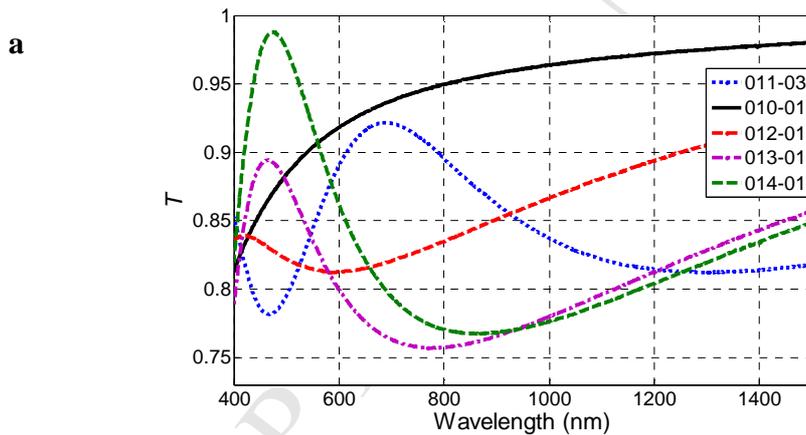
In order to determine the effective refractive index of the compTiO<sub>2</sub> layer, a published technique [27] based on spectral transmission ( $T-\lambda$ ) measurements with different angle of incidence was adopted. The transmission spectra for seven different angles of incidence for perpendicularly polarized light (s-pol.) as function of wave number  $k$ , are shown in Figure 4. These curves show distinct Fabry-Perot resonances due to reflections at the thin film boundaries. It is observed, that these oscillating curves start to be distorted as the angle of incidence increases, leading to two extrema (i.e. one maximum and one minimum) in the case of 60° instead of three at other angles of incidence. A jump at 800 nm ( $k = 12.5 \cdot 10^3 \text{ cm}^{-1}$ ) emerges at increasing angles of incidence, which is due to the detector change in the spectrometer that is not fully compensated because of the beam displacement in our modified setup. Another jump observed in the spectra at 360 nm originates from the source change from the visible to the ultraviolet lamp. The influence of this jump is excluded in Fig. 4 by restricting the regarded spectral range to larger wavelengths (larger than 360 nm,  $k < 27.7 \cdot 10^3 \text{ cm}^{-1}$ ), as the range of smaller wavelengths has absorptions and is not well suited for Fabry-Perot analysis.

As known (see e.g. [27, 30]), the positions of the interference extrema (i.e. of the maxima and minima) on the wavenumber scale ( $k_{ext}$ ) show a linear dependence on the extremum number ( $M_a$ ). This number is correlated with the usual [30] interference order  $N$  by a linear relationship:  $2N = M_a + M_o$ , where the offset ( $M_o$ ) depends on the specific measurement technique. Whereas the interference order is usually the difference between the number of wavelengths in two consecutive light paths, the extremum numbers ( $M_a + M_o$ ) are the difference between the numbers of half wavelengths in these paths.

Accordingly, the  $k_{ext}-M_a$  dependence was fitted with a straight line for each angle of incidence as shown in Figure 5. Also the maximal and minimal possible values were estimated for the error

determination. The slope  $m$  of this line delivers the thickness-dependent part of the optical path difference  $\Delta_d = (2m)^{-1}$ . It differs from the total path difference  $\Delta$  by the phase jump due to the reflection on the optically dense-to-thin interface:  $\Delta = \Delta_d + \lambda/2$ . The dependence of  $\Delta_d$  on the incidence angle  $\alpha$  for s-polarized light is given by  $\Delta_d = 2d\sqrt{n^2 - \sin^2\alpha}$  and is plotted in Figure 6. Here, a linear relationship must be valid based on the laws of classical wave optics. Therefore, the experimental points were fitted with a linear curve and all deviations are ascribed to measurement errors. This induces the error in the refractive index and in the thickness. As a result, the refractive index for the compTiO<sub>2</sub> was determined to be  $1.7982 \pm 0.005$ , while the thickness was found to be  $(264.0 \pm 1.5)$  nm.

The refractive index determined from this sample can now be used as an input parameter for a fast and accurate thickness determination of all samples made by the described fabrication technique. Such investigations reveal the expected dependence of the thickness on the spin-coating rotation speed, but also a surprisingly high influence of other fabrication parameters (e.g. the support shape) on the thickness. Since these influences affect a geometrical parameter only and leave the fabricated material unchanged, we shift this topic to future works. The wavelength dependence of the refractive index will be discussed in Section 3.4.



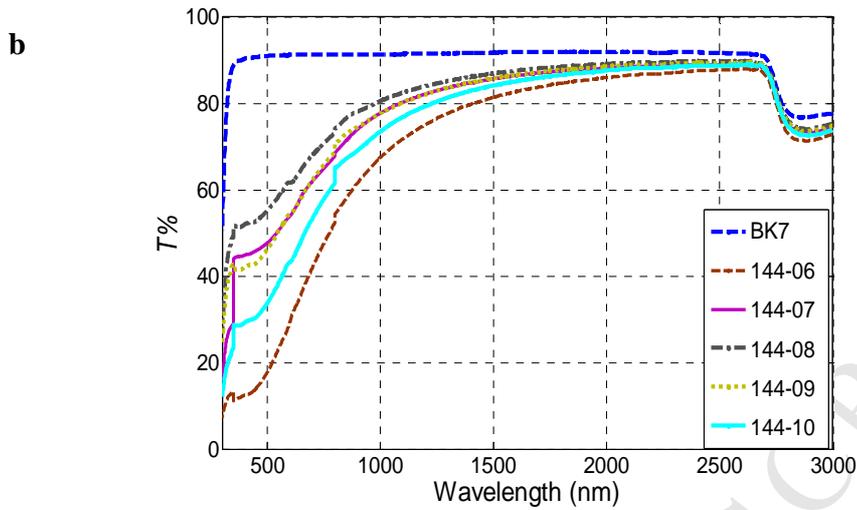


Figure 2: (a) Transmission spectra for the compTiO<sub>2</sub> layer for different spin coating procedures. The oscillations result from an interplay between Fabry-Perot resonances and absorption effects. (b) Transmission spectra for mpp-TiO<sub>2</sub> layers on glass substrates for the different samples of one batch. The discontinuities at 360 nm and 800 nm are due to lamp and detector changes, respectively.

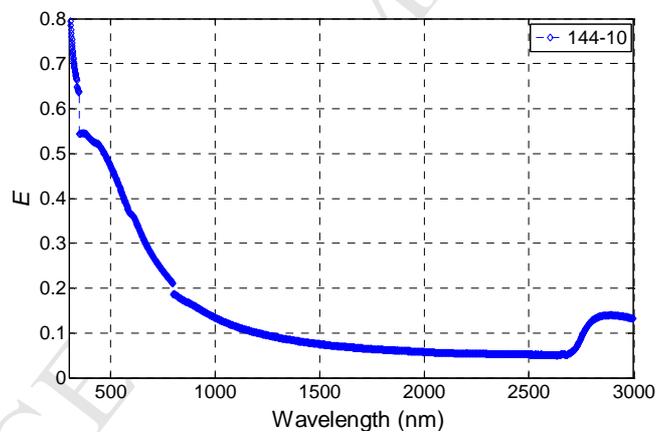


Figure 3: Extinction spectrum of the mpp-TiO<sub>2</sub> layer, sample 144-10. The discontinuities at 360 nm and 800 nm are due to lamp and detector changes, respectively.

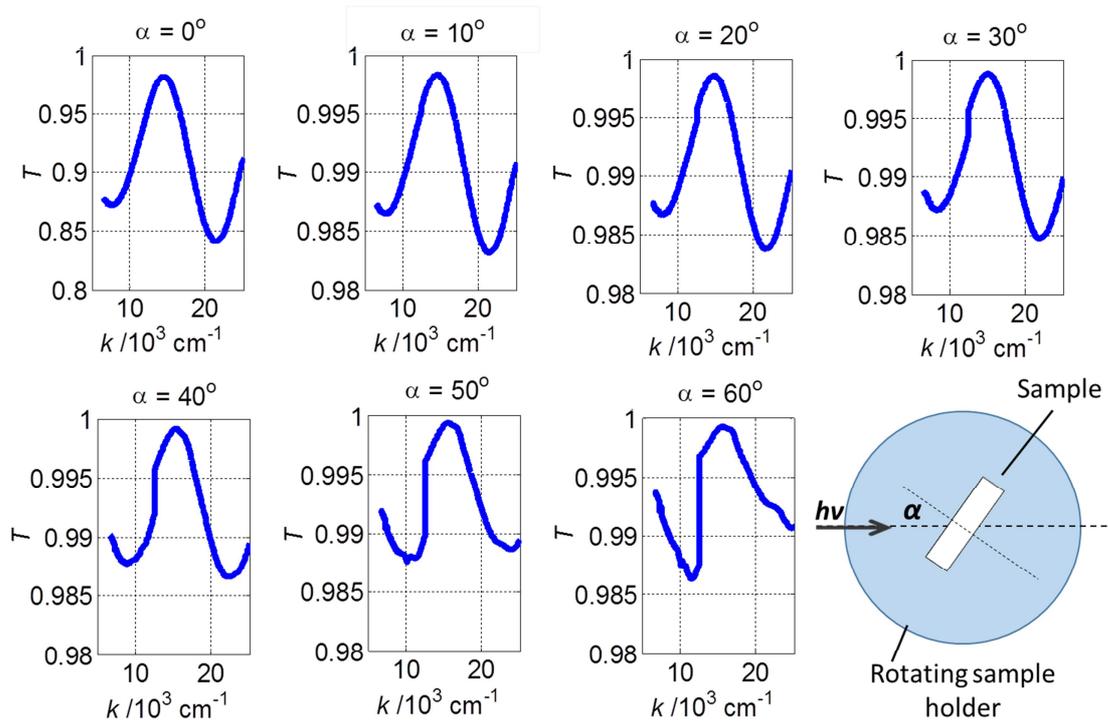


Figure 4: The optical transmission spectrum of a compTiO<sub>2</sub> layer at different angles of incidence for sample 011-03. The drawing (bottom, right) shows the experimental setup.

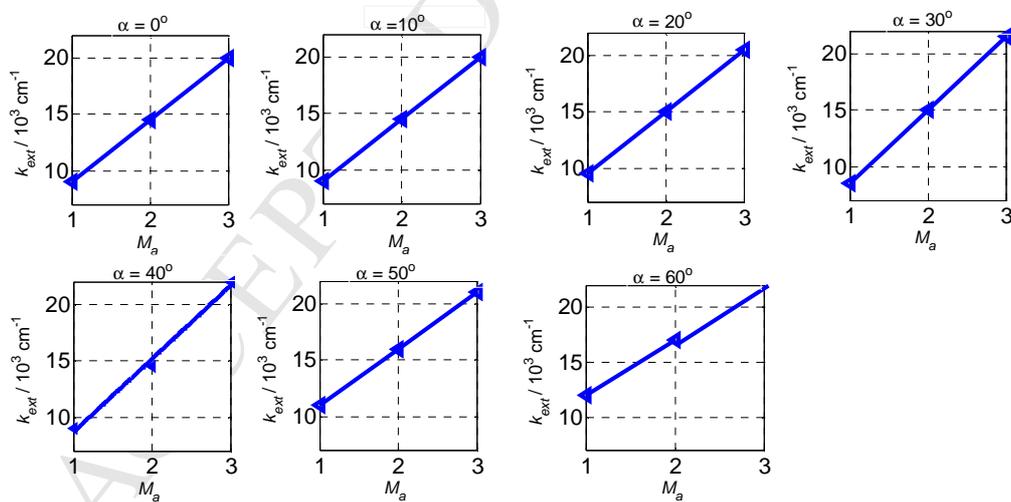


Figure 5: The extremum positions (i.e. maximum and minimum position) in the transmission spectrum versus extremum number (see text) for all observed extrema at different angle of incidence.

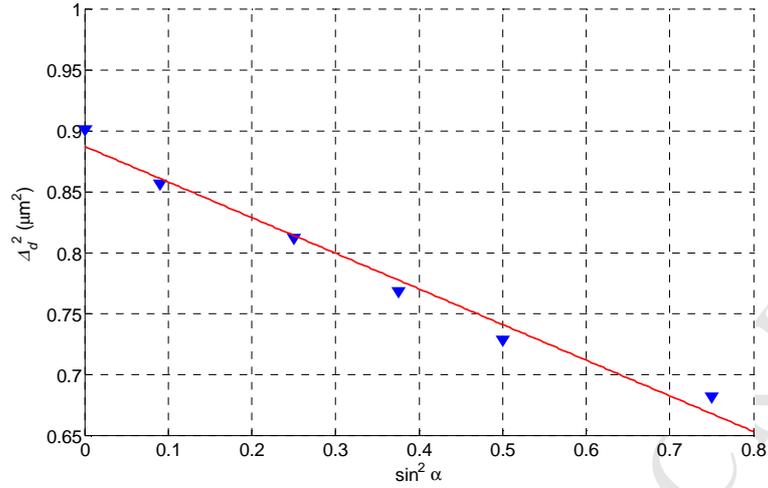


Figure 6: The square of the optical path difference  $\Delta_d$  versus  $\sin^2\alpha$ . The line represents a linear fit.

### 3.3. The effective refractive index of the mesoporous particle layer

The transmission spectrum of the mpp-TiO<sub>2</sub> films (Figure 2b) shows a completely different behavior compared to the compact films (Figure 2a). No Fabry-Perot oscillations are visible; instead there is a big part of the extinction which is obviously caused by scattering. Therefore, the angular-dependent spectral transmission ( $T$ - $\lambda$ ) method for determining the effective refractive index used above cannot be applied for the mesoporous layer. However, one can recognize a part in the spectrum (between 2000 and 2700 nm) where the extinction is low and nearly constant. We ascribe this low extinction to the reflection loss at the sample support (Figure 7). However, the support is in physical contact with the mpp-TiO<sub>2</sub> and, therefore, this reflection loss is influenced by the properties of the mpp-TiO<sub>2</sub>. We have used the Fresnel formula for describing this effect from which we calculated the effective refractive index.

The transmitted power,  $T_{SRL}$ , where SRL stands for support reflection loss, is thus calculated using:

$$T_{SRL} = 1 - R_{BK7} - R_{mp/BK7} \quad (1)$$

$$R_{BK7} = \left( \frac{n_{BK7} - 1}{n_{BK7} + 1} \right)^2 \quad (2)$$

$$R_{mp/BK7} = \left( \frac{n_{mp} - n_{BK7}}{n_{mp} + n_{BK7}} \right)^2 \quad (3)$$

where  $R_{BK7}$  is the reflectance between air and the glass substrate (BK7),  $R_{mp/BK7}$  stands for the reflectance between the BK7 and the mesoporous layer, and  $n_{mp}$  is the effective refractive index of mpp-TiO<sub>2</sub>. The value of  $R_{BK7}$  is equal to 0.04 [26]. This value was verified in the

measurements shown in Figure 2b where the transmission of a normal BK7 glass layers from front and back side was found equal to 0.92. Solving the second order equation in  $n_{mp}$  resulting from (1)-(3), two values for the refractive indexes were found: 1.463 and 1.625.

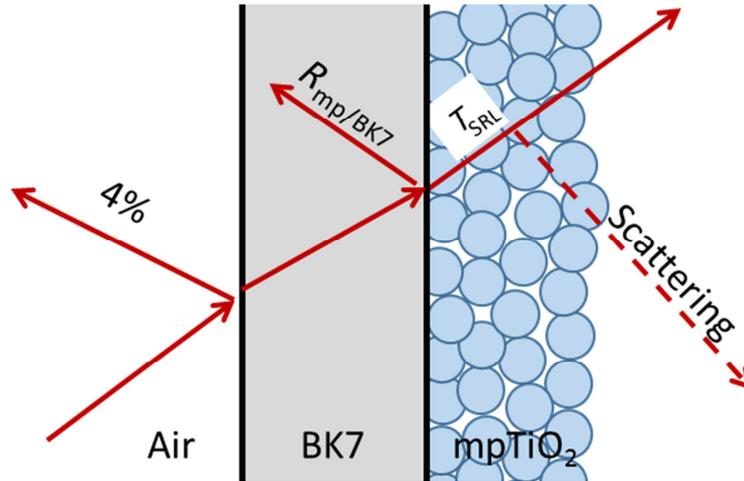


Figure 7: Schematic of the supported mesoporous Titania films used for calculating the support reflection loss (SRL)

To pick up the correct value from the two determined results, and for verifying the measurements, the same experiment was repeated on a quartz substrate instead of BK7. The same set of equations ((1)-(3)) was used (but with replacing BK7 by quartz glass). The refractive index of quartz glass is 1.46 [26]. Solving the equation to get  $n_{mp}$ , these two values were found: 1.621 and 1.315. Since only one of these values is delivered from both experiments with small deviation from each other ( $1.623 \pm 0.002$ ), we rule out the other results. Repeating the same procedure on five samples (144-06 to 144-10), the mesoporous particle layer refractive index was found to be in the range of  $1.628 \pm 0.006$ . Obviously, the unavoidable fluctuations in the manual screen printing technique used here did not affect the effective refractive index much. The obtained value refers to the used particle size and fabrication technique. By changing the particles size or deposition technique, new values should be expected [31]. However, other parameters such as support surface treatment will only have a soft influence on the optical properties of the film. Such influences are a principle difficulty for all tunable materials.

In order to calculate the porosity ( $P$ ) of the film, a linear dependence between the porosity ( $P$ ) and the square of the refractive index (i.e. the relative permittivity  $\epsilon$ ), was assumed. Giving that  $\epsilon = \epsilon' + j\epsilon''$ , where  $\epsilon'$  and  $\epsilon''$  are the real and imaginary part of the permittivity respectively, the following mixing rule with respect to the porosity and the real part of the background refractive index is assumed:

$$\epsilon' = \epsilon'_B - P(\epsilon'_B - 1) \quad (4)$$

where  $\epsilon'_B$  is the real part of the permittivity of the background bulk  $\text{TiO}_2$  ( $\epsilon'_B = 5.75$ ) (at  $\lambda = 550$  nm) [32]. Applying equation (4), the porosity of the mesoporous layer is found to be  $(65.2 \pm 0.2)$  %. A comparison of this value with adsorption data is challenging because of the film geometry

of the sample and the weight of the support. Possibly, reliable data can be obtained by Kr adsorption measurements [33].

### 3.4. Dispersion and absorption of the compact TiO<sub>2</sub>

Up to now, dispersion and absorption of the films were neglected. However, the data for the compact layer enable a well-based prediction of these effects. For that, we determine the porosity of the films. The value 53.5% is found using the same approximation as in the last section with the refractive index determined as in section 3.2. We use this porosity value and literature data of the bulk material [34], for calculating the parameters of the porous system applying the simple mixing rule given in equation (4). A Lorentz-Drude (LD) fitting model as developed in [35] was applied to the background material (TiO<sub>2</sub>), allowing easy data handling in future DSSC simulations. Figure 8a shows the achieved result

For describing the absorption of the compTiO<sub>2</sub> layer, the imaginary part of the refractive index is estimated based on the absorption data in [34] and by applying the same effective medium approximation as in (4). This approximation implies the same mixing rule between the porosity and the imaginary part of the permittivity given by:  $\varepsilon'' = \varepsilon_B'' - P\varepsilon_B''$ , where  $\varepsilon_B''$  represents the imaginary part of the permittivity for the bulk TiO<sub>2</sub> and  $P$  is the porosity as calculated above. Again, LD fitting is used and the results for  $\varepsilon''$  are shown in Figure 8b.

### 3.5. Scattering in the compact layer

To simulate light interaction within a compact layer on a glass substrate, we used the finite difference time-domain (FDTD) algorithm. For the implementation of the numerical layer model, we adopted the open-source FDTD platform embedded in MEEP [36]. The simulated volume is chosen to be 100  $\mu\text{m} \times 100 \mu\text{m} \times 100 \mu\text{m}$  with a calculating grid of 10 nm  $\times$  10 nm  $\times$  10 nm and the resolution is set to 10, (i.e. 10 meshes per calculating grid).

Figure 9 shows the simulation result in comparison with the measurement. One can see a small mismatch between the measured transmission spectrum of sample 011-03 and its simulation using the optical parameters calculated in the previous sections. The simulated layer thickness is chosen to be 264 nm. The apparent mismatch seems to be constant between the wavelengths 500 nm and 2000 nm. As this region is free of any absorption in TiO<sub>2</sub> as shown in Figure 8b and reported in the literature [29], we consider this mismatch to be due to scattering.

In general, scattering may be associated to surface or volume scattering. Surface scattering is most probably due to the roughness of the surface while bulk scattering is usually related to interaction with disturbances inside the layer. According to the surface roughness measured in [27, 37], the samples show a very flat surface over the whole film, with a root mean square (RMS) roughness around 0.50 nm in a (0.5  $\mu\text{m}$ )<sup>2</sup> region. Therefore, a bulk scattering model is more likely for the compact layer.

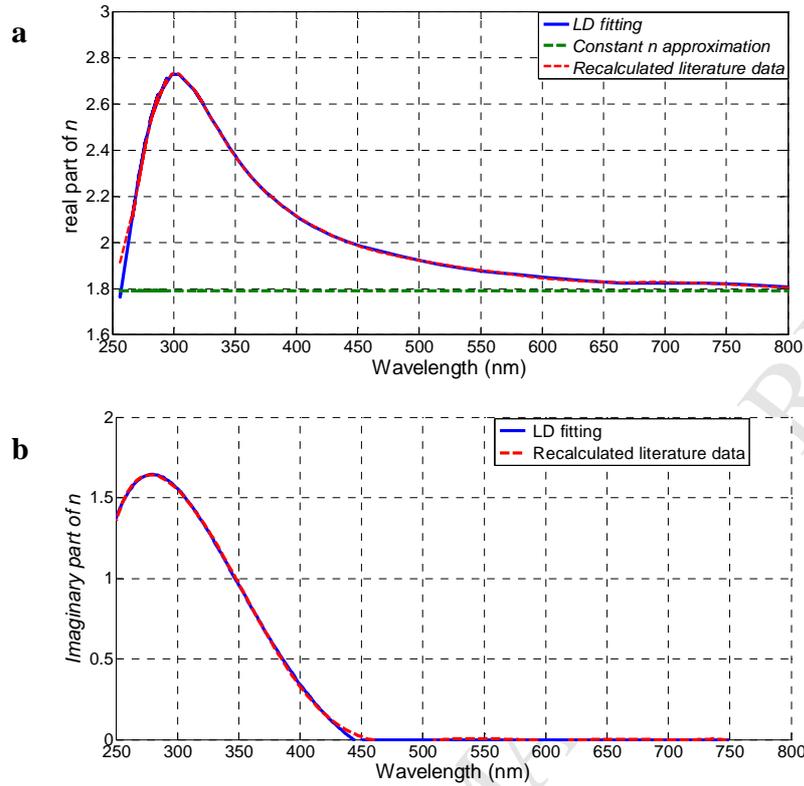


Figure 8: (a) Dispersion of compTiO<sub>2</sub> based on ref. [28]. (b) Imaginary part of the refractive index versus wavelength for a compTiO<sub>2</sub> layer based on ref. [28]. The LD fitting parameters for (a) and (b) are:  $\epsilon_{\infty}=1$ ,  $\sigma_1=2.4221\text{e}+41$ ,  $\omega_1=0.13145$ ,  $\Gamma_1=0.011715$ ,  $\sigma_2=8.9217$ ,  $\omega_2=0.64888$ ,  $\Gamma_2=5.2313$ ,  $\sigma_3=0.50133$ ,  $\omega_3=3.6165$ , and  $\Gamma_3=0.85456$ , according to the model in [35].

Many models for bulk scattering have been described in the literature [38, 39]. Rayleigh and Mie scattering are two of the simplest models for volume scattering effects ascribed to single particles of special properties. Wavelength-independent scattering is another simplified description useful for scattering events from objects much larger than the wavelength. Mathematically their introduction can be easily done by adding a wavelength-independent part to the imaginary part of the refractive index [40].

To explore the influence of this simple volume scattering model, an additional simulation parameter is introduced in the imaginary part of the refractive index, so that the complex refractive index of the compact layer becomes  $n + j(K + K_{sca})$ , where  $K_{sca}$  is the new parameter. We introduce the scattering parameter in the  $n$ -model instead of an  $\epsilon$ -model because this is more near to the physical process of scattering losses resulting in an exponential decay of intensity. A little surprisingly, this single additional parameter leads to a perfect fitting between simulation and experimental data in the whole spectrum as shown in Figure 9 (dotted line) for a value of  $K_{sca} = 0.20384$ .

### 3.6. Scattering in the mesoporous layer

Let us choose the region of interest for the optical investigation of the mpTiO<sub>2</sub> layer to extend to the wavelength range from 450 nm to 2500 nm where no absorption is observed. Therefore, we can ascribe the reflection-corrected extinction spectrum shown in Figure 10 (dotted line) to scattering effects only.

For the mpp-TiO<sub>2</sub>, the scattering is clearly wavelength-dependent. Therefore, the applied model for the compact layer is not valid here. The extinction spectrum is used in describing the scattering within the mpp-TiO<sub>2</sub> layer instead of the transmission spectrum used for the CompTiO<sub>2</sub> layer because the logarithmic scale is better suited for displaying the large intensity changes and because known microscopic scattering models deliver this value. The accurate description of the scattering of a mesoporous film is, however, difficult and requires detailed information of the underlying micro structure. Therefore, we use the Mie model [38, 39] as simple phenomenological description of the wavelength-dependent scattering effects. The parameters of the model have to be regarded as effective parameters with restricted physical meaning. A Matlab-based Mie scattering model in [41] was therefore applied on the extinction data where two fitting parameters have to be adjusted, namely the effective scattering particle radius and the scattering prefactor. The scattering prefactor is an aggregated parameter that depends on the effective scattering particle density, the scattering layer thickness, and the aperture of the spectrometer detector.

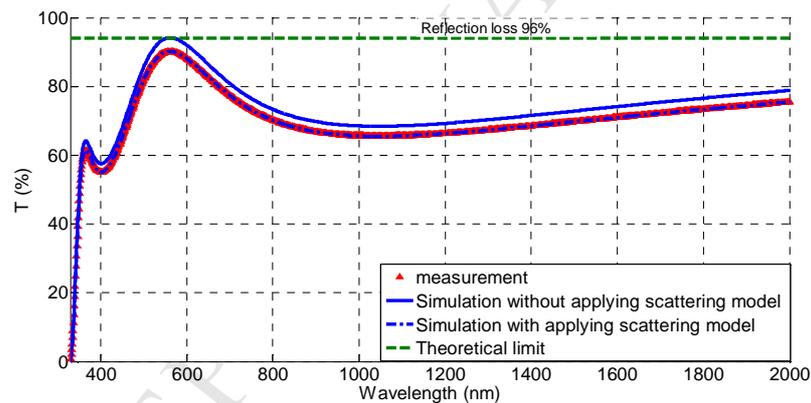


Figure 9: Measurements versus simulation transmission spectrum for a compact layer (sample 011-03)

In order to capture the required fitting parameter for the Mie scattering model, a fitting procedure was applied using Matlab [41]. The fitting process was affected by the jump in the measured extinction curve at 800 nm. This jump is due to the change of the detector made by the UV-Vis spectrometer, where a UV-Visible detector is replaced by an infrared one. To overcome the discontinuity and to obtain more accurate fitting results, we divided our extinction curve into two regions of interest. The first is from 450 nm to 800 nm, while the second is from 800 nm to 2500 nm. Each of these regions is then fitted independently.

The fitting was made on a sample on BK7. The effective scattering particle radius in both regions was found to be 46.5 nm with an error of about 2.5 nm in the two regions, respectively. The constant radius in the two regions is compensated by the variation in the prefactor

parameter. The surprisingly high agreement between the measured and the simulated data is shown in Figure 10. To verify the results, we repeated the analysis for mpTiO<sub>2</sub> on a quartz glass support. The same effective scattering particle radius was found but with other values for the scattering prefactor.

This invariant radius of effective scattering particle is expected as in both samples, the scattering occurs due to the same scattering medium. The different prefactors reflect the use of two different spectrometer detectors with two different aperture values and differences in the sample thickness from one sample to another, due to the use of a manual deposition technique. Therefore, we consider the 46.5 nm as a well-justified value for the radius of the effective scattering particles in the mpp-TiO<sub>2</sub> layer. This value can be used in future simulation of the scattering effects in conjunction with the Mie scattering model. However, it should be noted that it is not directly correlated to the actual particle radius in the mpp-TiO<sub>2</sub> film.

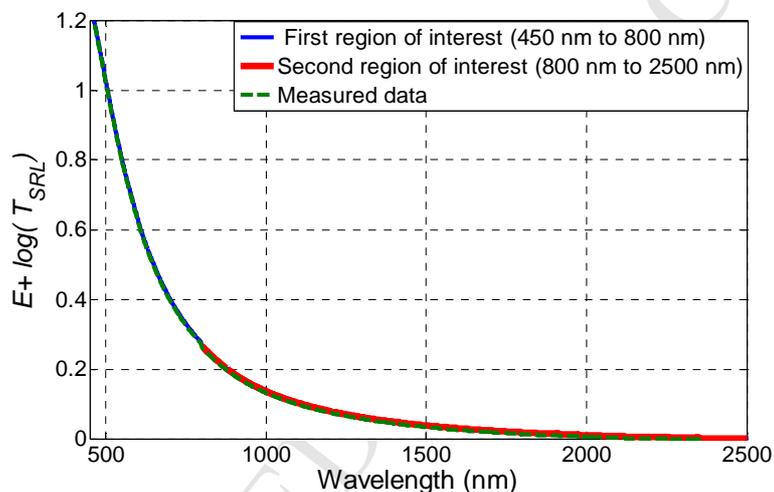


Figure 10: Fitting model based on Mie scattering for mpTiO<sub>2</sub> on a BK7 support.  $T_{SRL}$  represents the transmission due to the SRL.

#### 4. Conclusions

The optical properties of compTiO<sub>2</sub> and mpp-TiO<sub>2</sub> films differ strongly from those of ordinary TiO<sub>2</sub>. The porosity of the solid and the scattering by inhomogeneities determine their characteristic behavior.

Using spectrally resolved transmission measurements, the refractive index of the compTiO<sub>2</sub> film was determined to be  $1.7982 \pm 0.005$ . For the mpp-TiO<sub>2</sub> layer where scattering effects are dominate, the effective refractive index was determined using the reflection loss, yielding a value of  $1.62 \pm 0.002$ . Assuming a simple mixing rule for the effective permittivity of the pours TiO<sub>2</sub>, the porosity of the compact layer was determined to be 53.5%, while that of the mesoporous layer is 65.2%.

In order to account for the mismatch due to scattering between the measured transmission spectrum of compTiO<sub>2</sub> and its simulation, a damping constant was introduced in the imaginary part of the refractive index to account for the frequency-independent scattering and found to describe the experimental data well. In the case of the mpp-TiO<sub>2</sub> layer, a Mie scattering model was found to be best suited to describe the frequency-dependent extinction spectrum. The radius of the effective scattering particles of 46.5 nm describes the data well and is in the same order of magnitude as the pore size of the layer. Therefore, we can conclude that the optical transport in these layers is determined by the intentional nanostructure and not by  $\mu\text{m}$ -scale defects occasionally occurring in these films.

The remarkably high porosity of the two investigated layers can also be expected to have a large influence on the ionic transport, on the charge screening, and on the mutual interaction of different kinds of charges in these semiconductors. For an understanding of that, data on pore sizes and interconnectivities are needed.

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## Appendix A. Supplementary data

Supplementary data related to this article can be found at XXXX

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## Refractive Index and Scattering of Porous TiO<sub>2</sub> Films

### Highlights

- Reliable methods for the determination of the refractive index of different TiO<sub>2</sub> films used in solar cells are described.
- Refractive index values for two titania films typically used in solar cells: 1.7982 and 1.62
- Porosities of these two titania typically used in solar cells: 53.5 % and 65.2 %
- Effective scattering particle radius in one solar-cell related titania film: 46.5 nm